## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

July 13, 2004

In re the Application of

Masaru MITSUI et al.

Group Art Unit: 1752

Application No.: 09/509,472

Examiner:

Y. Thornton

Filed: April 21, 2000

Docket No.: 105875

For:

PHOTOMASK BLANK, PHOTOMASK, METHODS OF MANUFACTURING THE SAME

AND METHOD OF FORMING MICROPATTERN

LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION OF TIME UNDER 37 C.F.R. §1.136(a) AND TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired January 13, 2004, an extension of time for a period of othree months is hereby requested. Attached hereto is our Check No. 156166 in the amount of \$950 in payment

	Extension fee for response within first month pursuant to §1.136(a) (\$110.00)
	Extension fee for response within second month pursuant to §1.136(a) (\$420.00)
XX	Extension fee for response within third month pursuant to \$1.136(a) (\$950.00)

The Commissioner is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

Respectfully submitted,

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JAO:CWB:JSA/wp

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DEPOSIT ACCOUNT USE **AUTHORIZATION** Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461